## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant: Yuanning Chen, et al.

Serial No.: 10/719,279

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Filed: 11/21/03

Art Unit: 2813

Examiner: Jack S.J. Chen

Docket: TI-35022.2

For: Use of Hafnium Silicon Oxynitride as the Cap Layer of the Sidewall Spacer

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that the above correspondence is being transmitted by facsimile to the U.S. Patent and Trademark

Office at 703-872-9306 on the date shown below.

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Karen Vertz

25-02

## **EXTENSION OF TIME**

Pursuant to 37 CFR 1.136(a), Applicants respectfully petition the Commissioner for an extension of the shortened statutory period for response in the above-identified Application.

The fee for this extension is indicated below:

Firet	Month	(\$120)

X Second Month (\$450)

Third Month (\$1,020)

\_\_\_\_ Fourth Month (\$1,590)

\_\_\_\_ Fifth Month (\$2,160)

Please charge the fee to deposit account No. 20-0668 of Texas Instruments Incorporated. The Commissioner is hereby authorized to charge any fees which may be required, or credit any overpayment to Account No. 20-0668. An original and two copies of this sheet are enclosed

Respectfully submitted

Rose Alyssa Keagy

Registration No. 35,095

Texas Instruments, Incorporated P. O. Box 655474 - M/S 3999 Patent Department Dallas, Texas 75265